

Energy Conversion by Semiconductor Devices

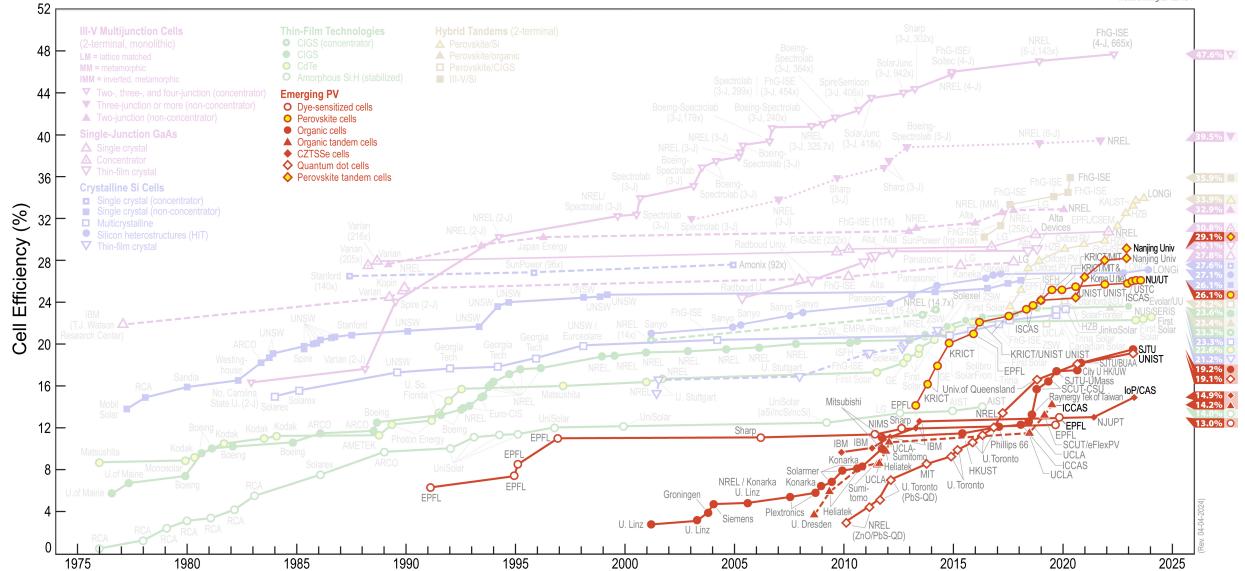
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EPFL Halide Perovskite

Best Research-Cell Efficiencies





EPFL What is Perovskite?

• 1839: perovskite = CaTiO₃ discovered

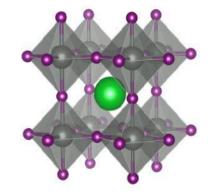


• 1958: CsPbX₃ (X = Cl, Br, or l) perovskite structure determined

Møller, C. K. Nature 182, 1436 (1958).

• 1978 Cs cation replaced by methylammonium cations CH₃NH₃⁺→ organic—inorganic hybrid perovskites

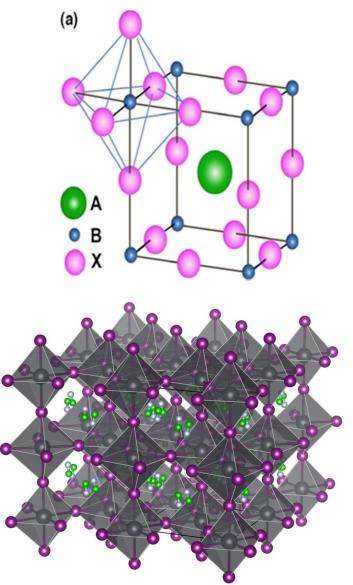
Weber, D. Z. Naturforsch. 33b, 1443–1445 (1978). Weber, D. Z. Naturforsch. 33b, 862–865 (1978).



Last two decades: perovskite researched in electronics

D. B. Mitzi, *Progress in Inorganic Chemistry* Vol. 48 (ed. Karlin, K. D.) 1–121 (J. Wiley & Sons, 1999). T. Ishihara, *Journal of Luminescence* **60–61,** 269–274 (1994).

EPFL What is Perovskite for Solar Cells?

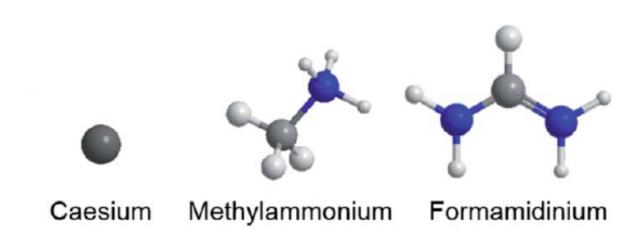


ABX₃:

A (green) is a large metal cation such as Cs⁺, CH₃NH₃⁺, HC(NH₂)₂⁺

B (blue) is a small metal cation such as Pb²⁺, Sn²⁺

X (purple) is Cl⁻, Br⁻, l⁻



Mono-cation: CH₃NH₃Pbl₃ (MAPbl₃ or MALI), HC(NH₂)₂Pbl₃ (FAPbl₃), CsPbl₃ Multi-cations: MA_xFA_{1-x}Pbl₃, Cs_xFA_{1-x}Pbl₃, Cs_xMA_yFA_{1-x-y}Pbl₃ (CsMAFAPbl₃)

Multi-anions: $MAPb(I_xBr_{1-x})_3$, $MAPb(I_xCI_{1-x})_3$

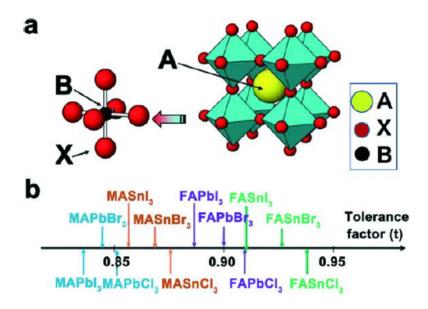
EPFL Goldschmidt Tolerance Factor & Octahedral Factor

In the typical ABX₃, the crystallographic stability and probable structure can be deduced by considering a Goldschmidt tolerance factor t and and octahedral factor μ .

The A cation can fit within the BX₃ framework of corner sharing octahedra.

The range from 0.8 to 1 indicates perovskite formation (t = 1) indicates a perfect fit).

$$t = \frac{R_A + R_X}{\sqrt{2}(R_B + R_X)}$$



Z. Fan et al., J. Mater. Chem. A, 3, 18809-18828 (2015).

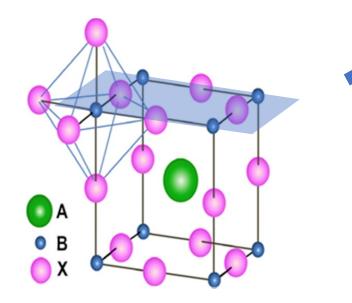
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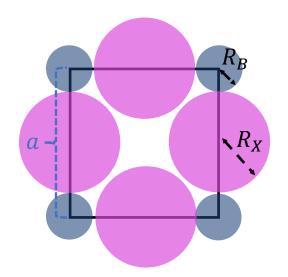
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$$t = \frac{R_A + R_X}{\sqrt{2}(R_B + R_X)}$$





$$a = 2R_B + 2R_X$$

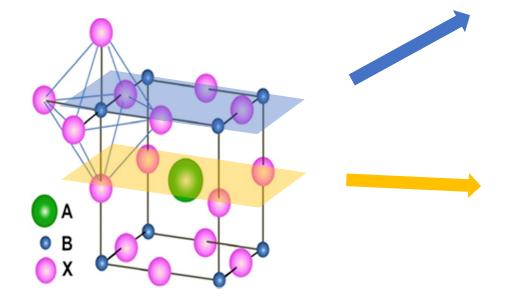
EPFL Goldschmidt Tolerance Factor & Octahedral Factor

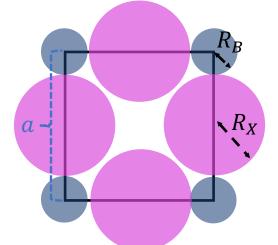
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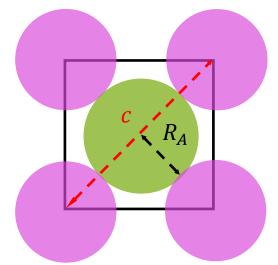
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$$t = \frac{R_A + R_X}{\sqrt{2}(R_B + R_X)}$$







$$a = 2R_B + 2R_X$$

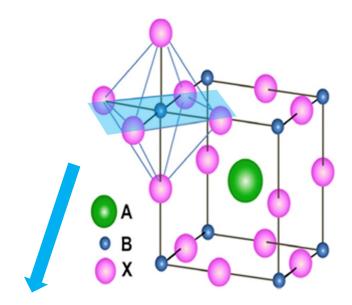
$$\frac{1}{\cos 45^{\circ}} = \frac{c}{a}$$

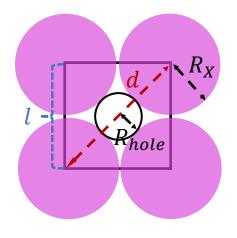
$$t = \frac{c}{\sqrt{2}a}$$

$$c = 2R_A + 2R_X$$

Goldschmidt Tolerance Factor & Octahedral Factor

In the typical ABX₃, the crystallographic stability and probable structure can be deduced by considering a Goldschmidt tolerance factor t and and octahedral factor μ .





$$l = 2R_X$$

$$d = 2R_{hole} + 2R_X = \sqrt{2} \times l$$
$$2R_{hole} + 2R_X = \sqrt{2} \times 2R_X$$

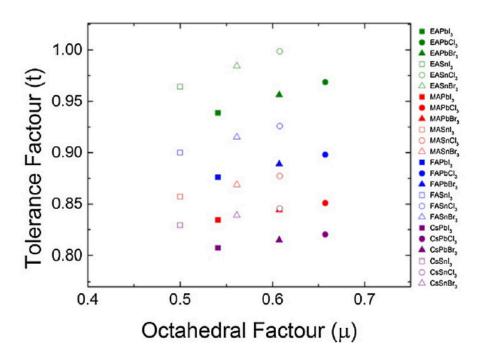
$$2R_{hole} + 2R_X = \sqrt{2} \times 2R_X$$

$$R_{hole} = (\sqrt{2} - 1)R_X$$

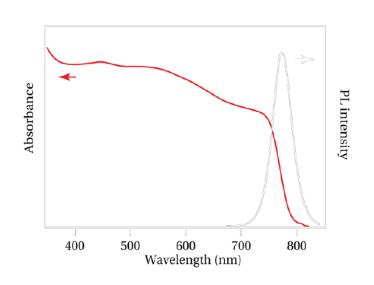
The B site cation can fit in the octahedral hole in the anion sublattice.

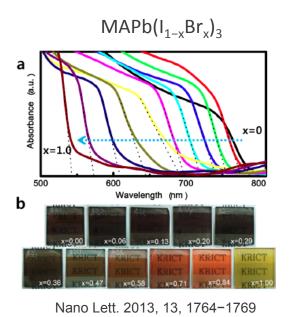
The radius of an octahedral hole formed within six close packed spheres of radius $(R_{hole}) = 0.41R_X$

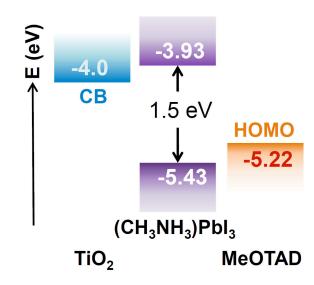
$$0.44 < \mu = \frac{R_B}{R_X} < 0.90$$



EPFL Organic-Inorganic Halide Perovskite

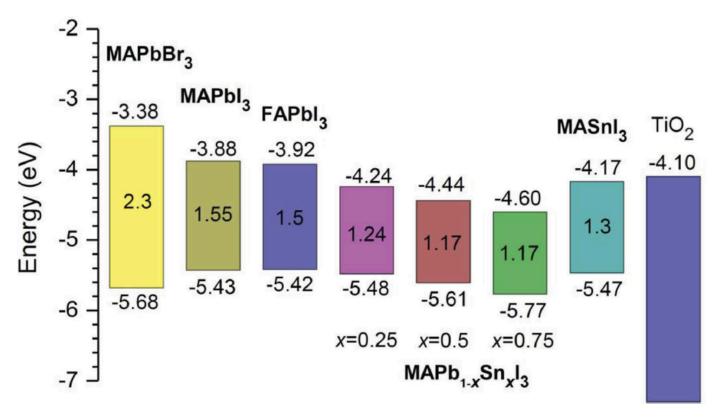


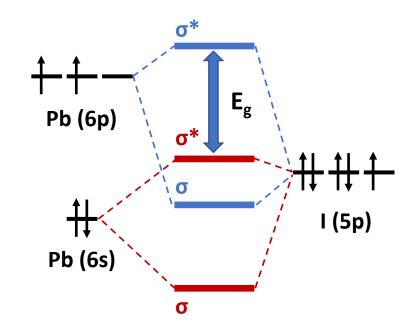




- High crystallinity and low defect density, even if solution processed
- Absorption coefficient of $10^4 10^5$ cm⁻¹
- Band gap of 1.6 eV and tunable band gap by compositional tuning (S-Q limit 33.7% with 1.34 eV)
- Proper energy levels to be compatible with existing ETM and HTM
- Ambipolar semiconductor with high charge carrier mobilities
- Low exciton binding energy with fast dissociation at room temperature, high dielectric constant

EPFL Band Gap Tuning



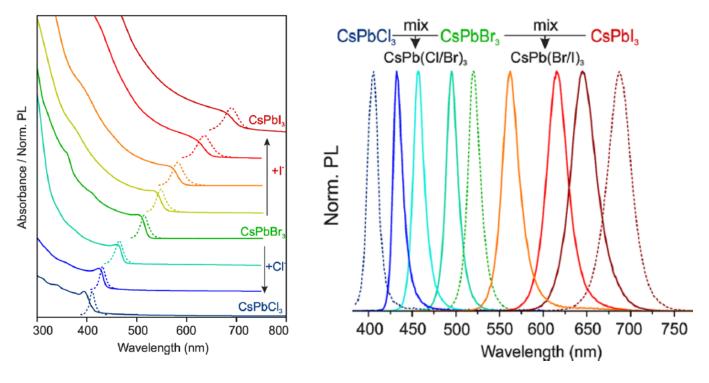


F. Hao et al., , J. Am. Chem. Soc., 136, 8094 (2014).

- CB formed by the antibonding combination of empty Pb 6p (Sn 5p) orbitals.
- VB formed by the overlap of Pb 6s (Sn 5s) orbitals and X halogen np orbitals.
- The octahedral layer angle distortion or H bonding strength change leads to a change in the band gap.

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EPFL Band Gap Tuning with X Anion



CsPbl₃ vs CsPbCl₃

CBM

E_{Pb,p}

VBM

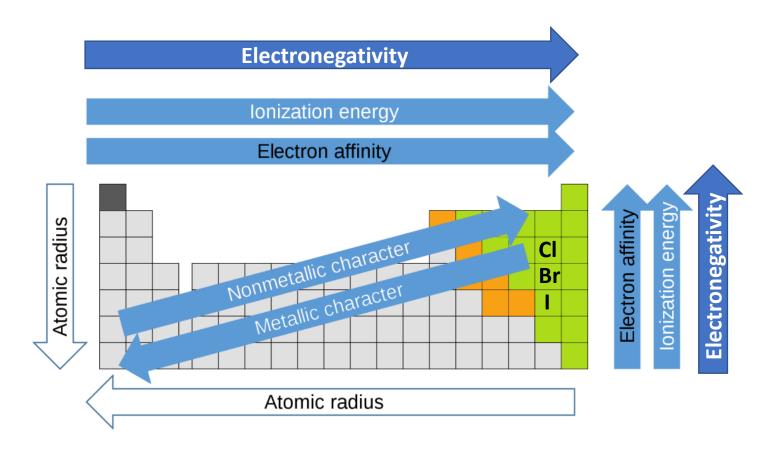
E_{Db,s}

G. Nedelcu et al., , Nano Lett., 15, 5635 (2015).

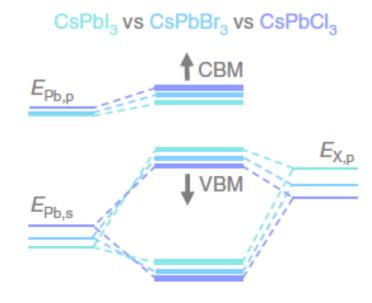
S. Tao et al., *Nature Commun.*, 10:2560 (2019).

- The energy of the CBM is mostly influenced by the position of the Pb p orbital.
- A small shift in CBM is associated with that as the Pb-X distances decrease going from I to Br to Cl, an electron on a Pb atom is more confined and its energy increases (reason of the upward shift of Pb p and s orbitals).
- A significant downward shift of the X p orbital level going from I to Br to Cl, which simply reflects increasing electronegativity.

EPFL Band Gap Tuning with X Anion

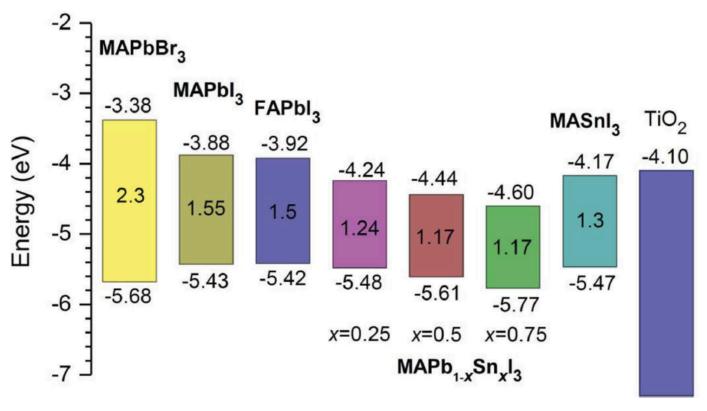


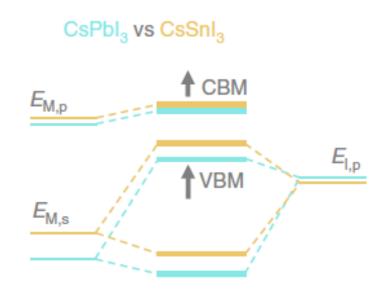
Electronegativity is defined as an atom's ability to attract electrons towards it in a chemical bond.



S. Tao et al., Nature Commun., 10:2560 (2019).

EPFL Band Gap Tuning with B Cation



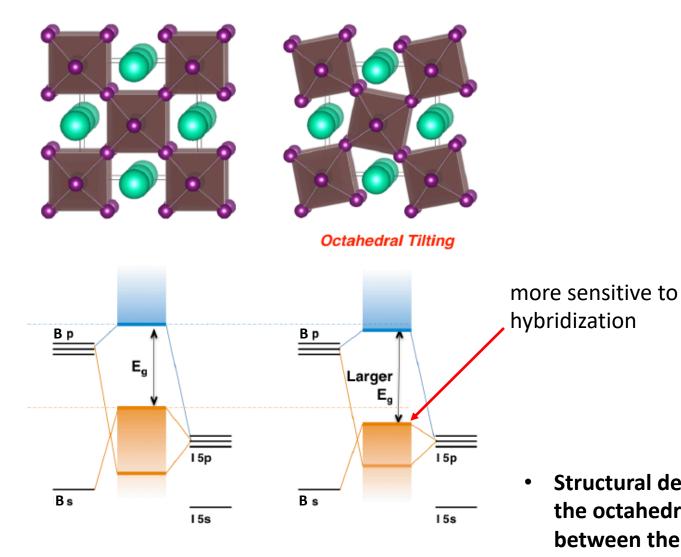


F. Hao et al., , J. Am. Chem. Soc., 136, 8094 (2014).

- S. Tao et al., *Nature Commun.*, 10:2560 (2019).
- Replacing Pb with Sn, the atomic levels shift upwards, which is consistent with the smaller electronegativity of Sn.
- The splitting between s and p states in a Sn atom is smaller than in a Pb atom: the VBM shifts upward more than the CBM.

EPFL

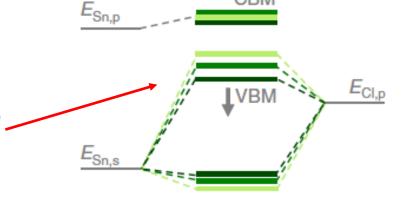
Band Gap Tuning with A Cation



R. Prasanna et al., J. Am. Chem. Soc., 139, 11117-11124 (2017).

 R_A : Cs^+ (1.81 Å) < MA^+ (2.70 Å) < FA^+ (2.79 Å)

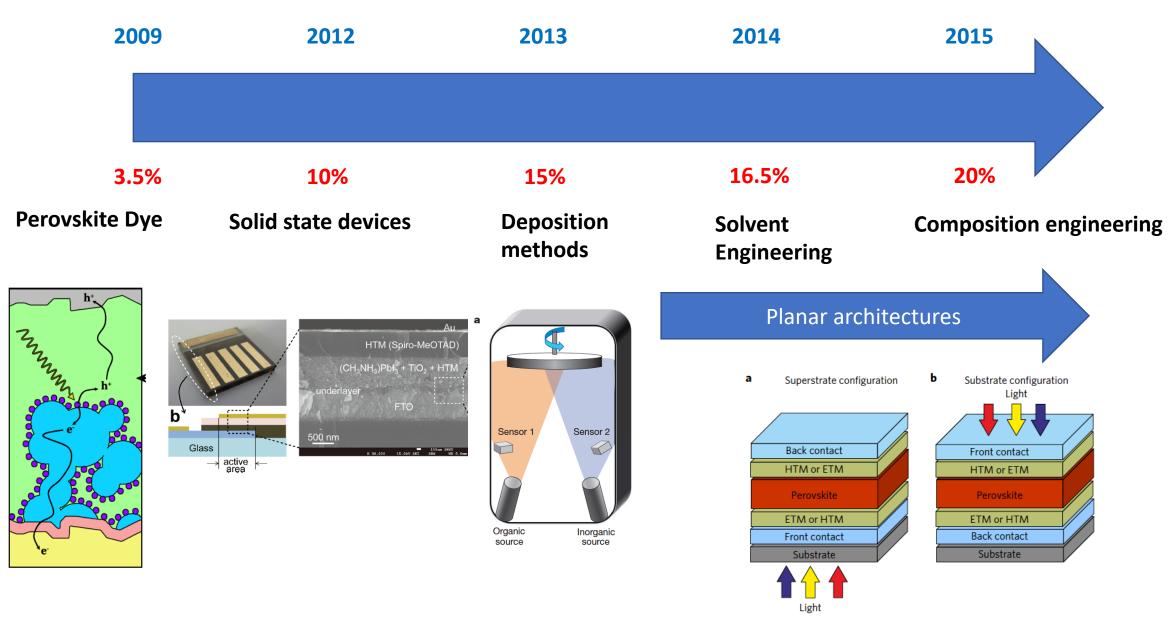
CsSnCl₃ vs MASnCl₃ vs FASnCl₃



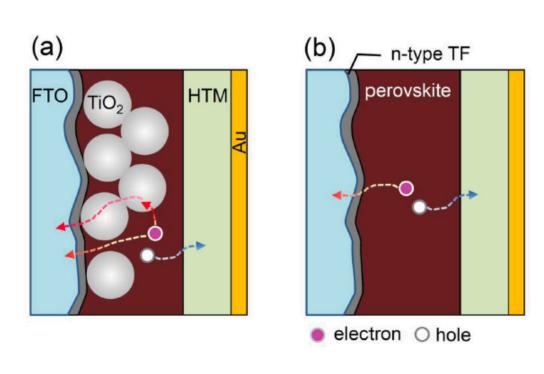
S. Tao et al., Nature Commun., 10:2560 (2019).

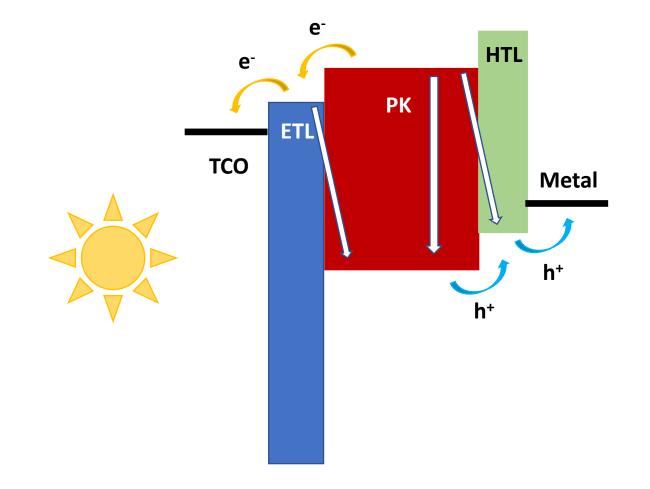
- Structural deformations (octahedral tilting and distortion) of the octahedra reduce somewhat the hybridization strength between the B and X states: This shifts the VBM and CBM downward.
- Increasing the size of A cation lower the B levels (moderated confinement): CBM slight shifts downward.

EPFL History



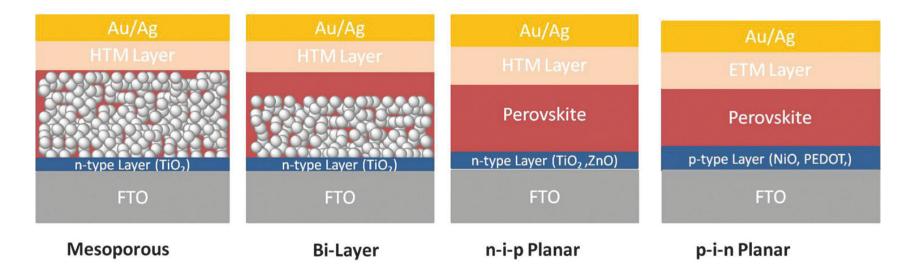
EPFL Operation Principle in PSC





F. Hao et al., , J. Am. Chem. Soc., 136, 8094 (2014).

EPFL Device Structures



Chem. Soc. Rev., 2016, 45, 655-689

TCO: ITO, FTO, etc

Low W_F metal for hole and high W_F metal for electron

ETL (n-type): Inorganic Materials (TiO₂, SnO₂, ZnO, etc) or Organic Materials (PCBM, C60, etc)

HTL (p-type): Inorganic Materials (NiOx, MoOx, etc) or Organic Materials (Spiro-OMeTAD, PTAA, PEDOT:PSS, etc)

SAM (p-type): MeO-2PACz, 2PACz

EPFL Device Structures

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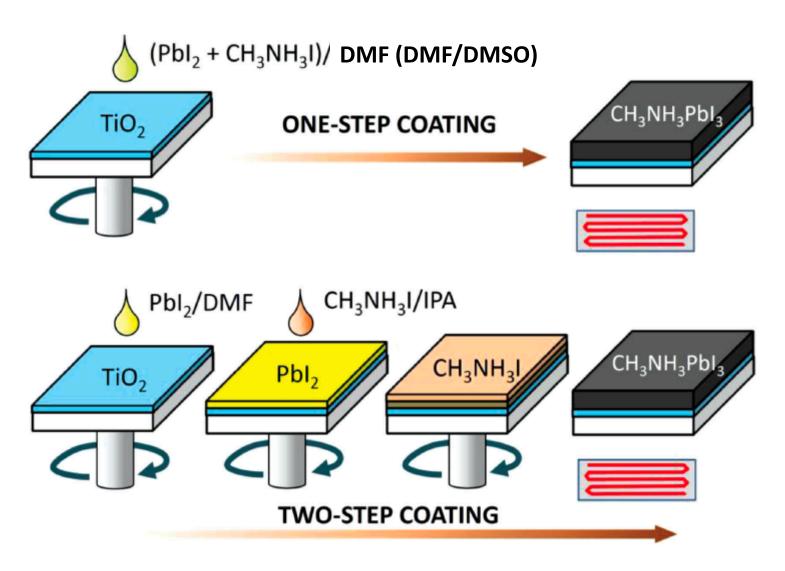
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EPFL Conventional Solution Process



Pbl₂, MAI as precursor

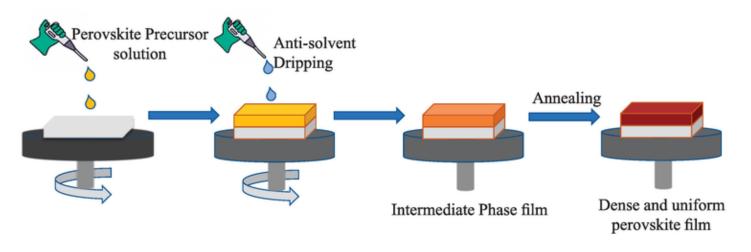
DMF: Dimethly Formamide DMSO: Dimethlysulfoxide

IPA: 2-propanol

F. Hao et al., , J. Am. Chem. Soc., 136, 8094 (2014).

EPFL Antisolvent Method

Antisolvent is a solvent in which your compound is less soluble. Ex) Chlorobenzene, Toluene, Green antisolvents: Diethyl carbonate, n-Ethane etc.



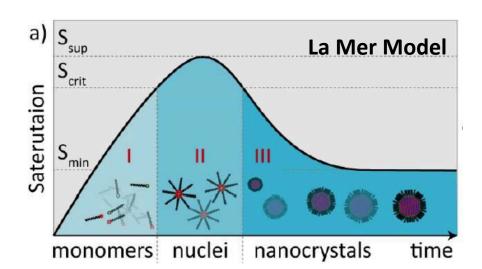
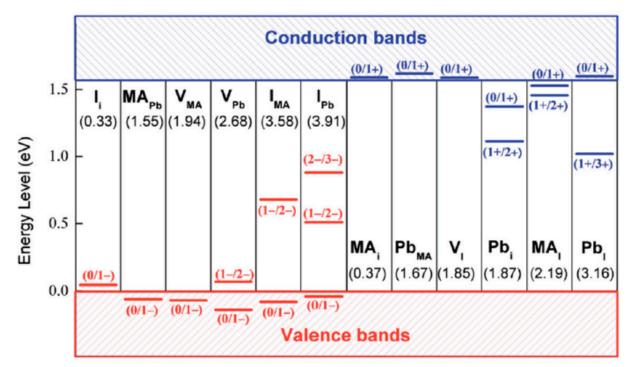


Image taken from "Thin Film Solution Processable Perovskite Solar Cells", IntechOpen, 2022.

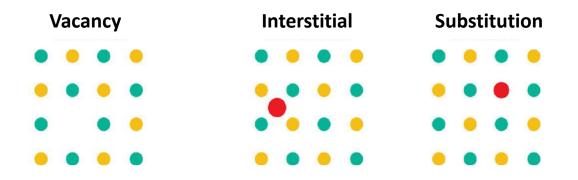
- The principle of antisolvent engineering is extracting the DMF/DMSO solvent using an antisolvent.
- This process leads to rapid oversaturation of the components, resulting in the formation of a target perovskite, after low temperature annealing.

EPFL Defect Tolerance

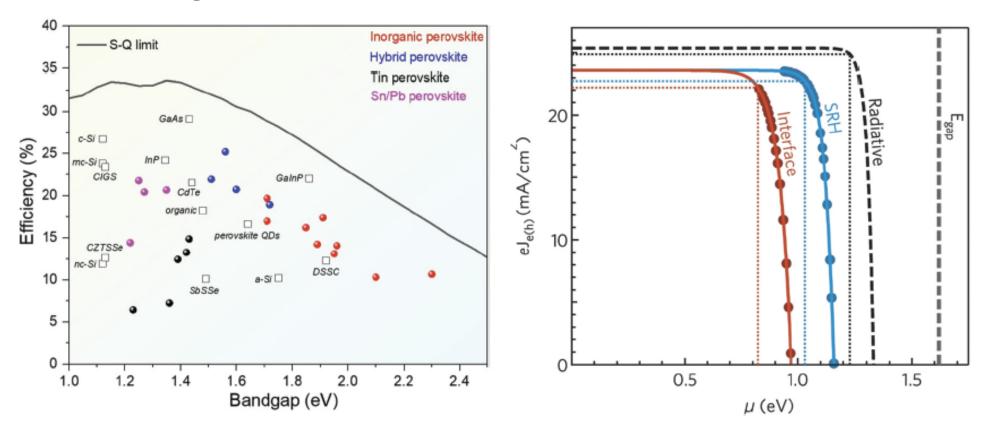
- Calculated transition energy levels of various type of point defects in MAPbl₃.
- Interstitials (i), vacancies (V), ion substitutions.
- Vacancy type defects produce shallow traps or resonance within the band.
- Some interstitials and substitutions associated with Pb and I form electronic states deep inside the band gap but have relatively high formation energies.



W-J. Yin et al., Adv. Mater., 26, 4653–4658 (2014).

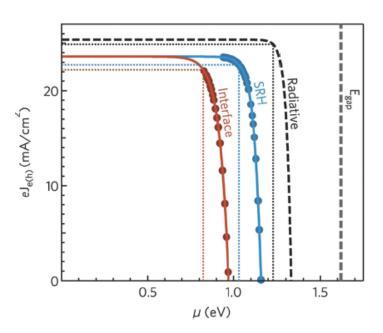


EPFL Towards Higher Performance



- Impressive efficiencies over 25% have been achieved.
- Room for further improvement.
- SRH non-radiative recombination by deep and shallow defects: film quality, crystal size, passivation.
- Interface recombination: energy alignment, charge extraction.
- Career management \rightarrow enhanced V_{oc} , J_sc and FF.
- Light management \rightarrow enhanced J_{sc} .

From J-V curve and IQE



 $EQE = IQE \times LHE$

IQE is determined by charge management, e.g. charge separation/collection.

Ideality Factor

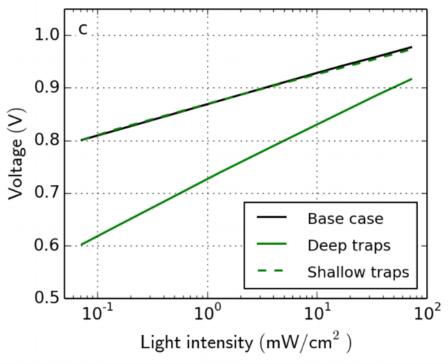
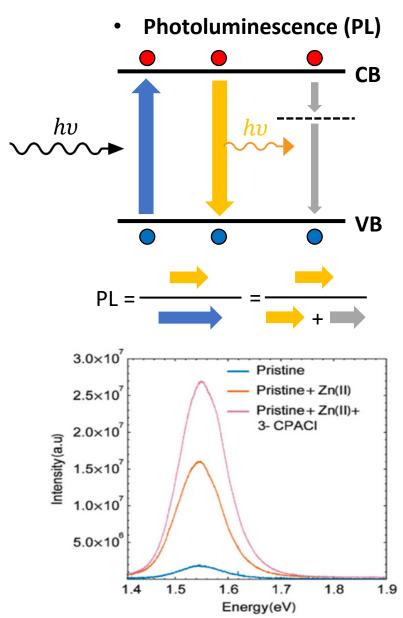


Image from https://www.fluxim.com

$$n = \frac{e}{k_B T} \cdot \frac{dV_{OC}}{d(lnL)}$$
 L is the incident photon flux

n = 1 is attributed to radiative recombination n = 2 is attributed to dominant SRH recombination

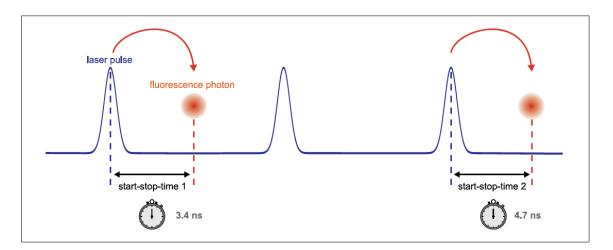


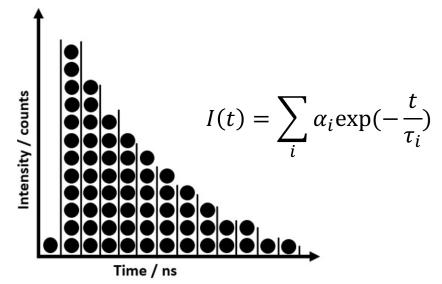
 PL quenching with CTL hυ **CTL** 4 x10⁶ CsFAPbIBr
CsFAPbIBr/PCBM
CsFAPbIBr/CL-ETL
Ex @ 450 nm 3 Ы 600 650 700 750 800 850

Wavelength (nm)

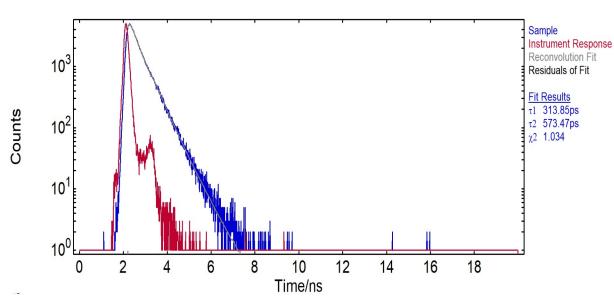
Image from L.A. Muscarella et al., *ACS Appl. Mater. Interfaces*, **11**, 17555 (2019)

Time-resolved PL

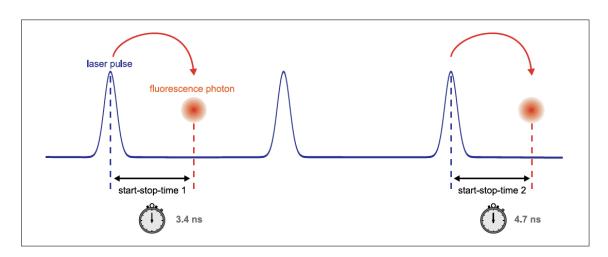


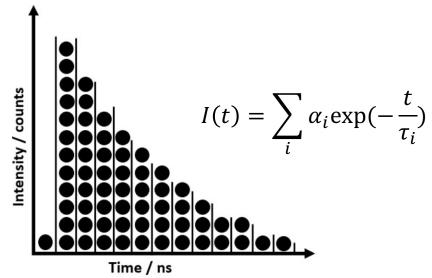


Time-correlated single-photon counting (TCSPC)

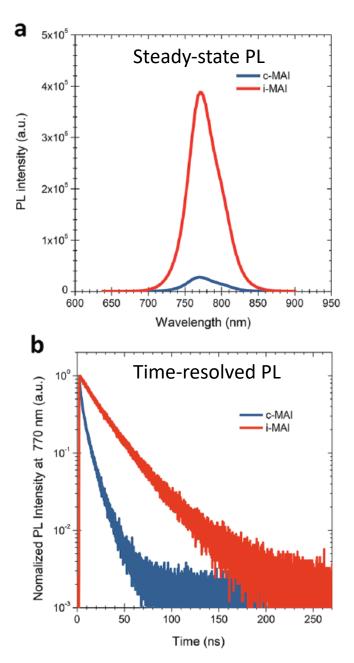


Time-resolved PL



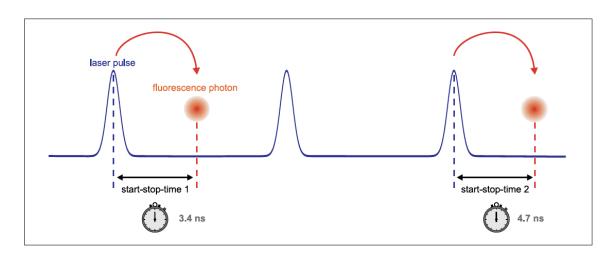


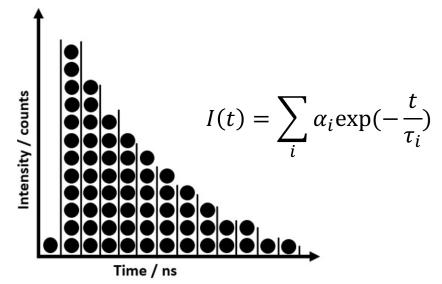
Time-correlated single-photon counting (TCSPC)



25

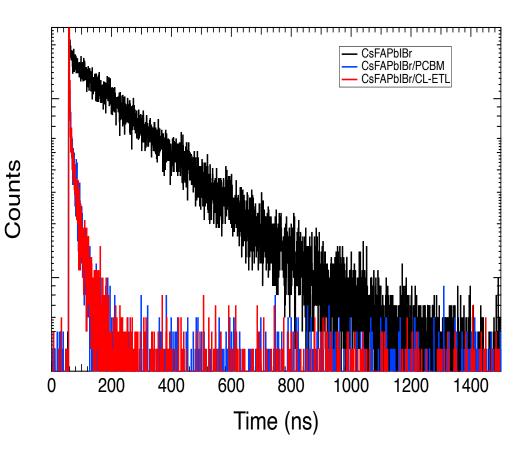
Time-resolved PL





Time-correlated single-photon counting (TCSPC)

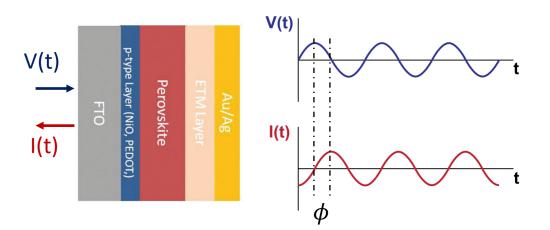
In general, the kinetics of the charge transfer to CTL is faster than the kinetics of radiative recombination.



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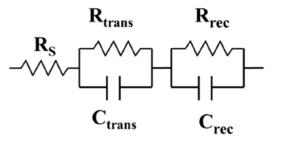
equivalent electrical circuit

• Electrochemical Impedance Spectroscopy (EIS)



$$Apply \rightarrow \Delta V(t) = V_0 sin(\omega t), \qquad \omega = 2\pi f$$

$$Response \rightarrow \Delta I(t) = I_0 sin(\omega t - \phi)$$



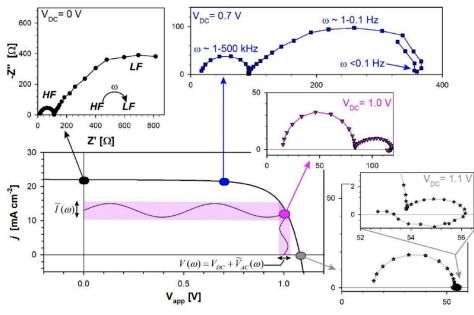


Image from A. Guerrero et al.,, Chem. Rev., 121, 14430 (2021)

$$impedance \equiv Z = \frac{\Delta V(t)}{\Delta I(t)} = \frac{V_0 sin(\omega t)}{I_0 sin(\omega t - \phi)} = Z_0 e^{i\phi} = Z_0 (cos\phi + isin\phi) = Z' + iZ''$$

The **impedance at a given frequency** is related to the **processes occurring at the timescales** imposed by the frequency.

Intensity-Modulated Photovoltage Spectroscopy (IMVS)

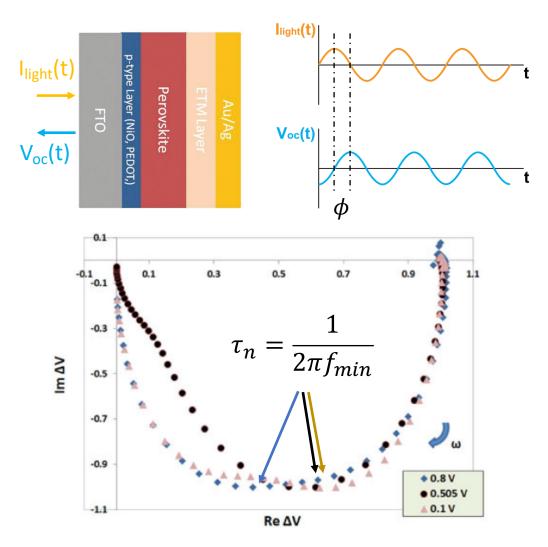
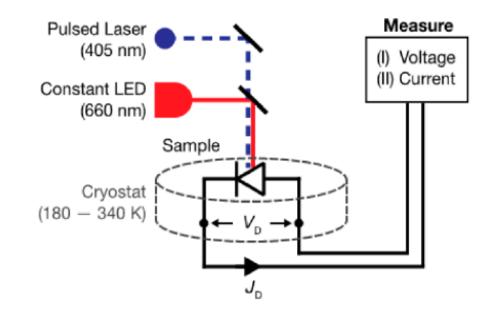
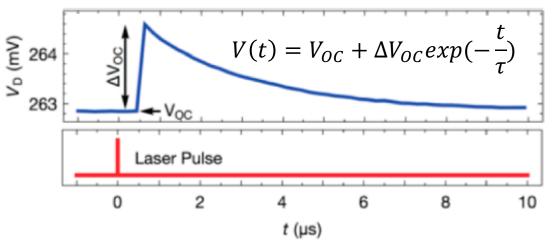


Image from K. Adhitya et al., IEEE J. Photovoltaics, 5, 1414 (2015)

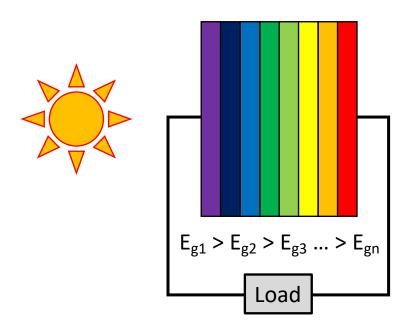
Transient Photovoltage Decay

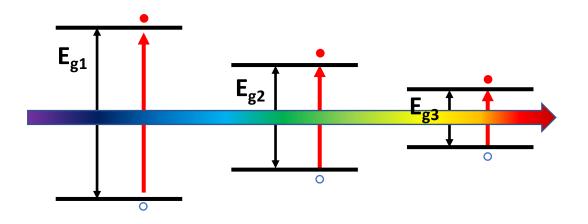




EPFL Beyond S-Q Limit

- Tandem Solar Cells
- Concentrated Solar Cells
- Intermediate Band Solar Cells
- Hot Carrier and Carrier Multiplication





- $V = V(E_{g1}) + V(E_{g2}) + V(E_{g3})$
- J is determined by the lower value

Tandem solar cells: Semiconductors with different bandgaps connected electrically in series either in the same device or in different devices.

Efficiency can be significantly enhanced by using a stack of materials with different band gaps.

- Efficiency >45% (dual junction) is possible under standard AM 1.5 illumination.
- Challenges:
 - Current matching required for series connection of junctions. Sensitive to illumination conditions.
 - Difficult to maintain a high crystal quality due to lattice mismatch.
 - High cost.

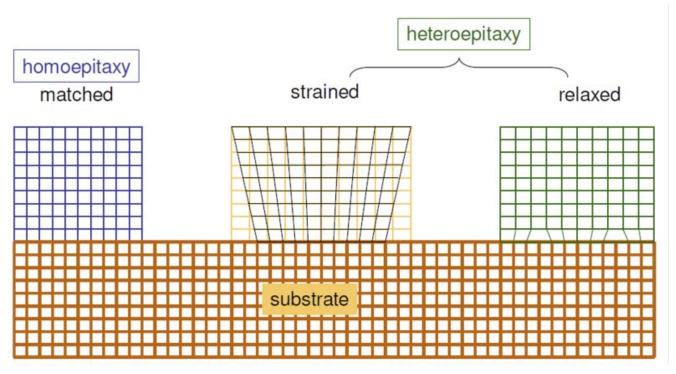
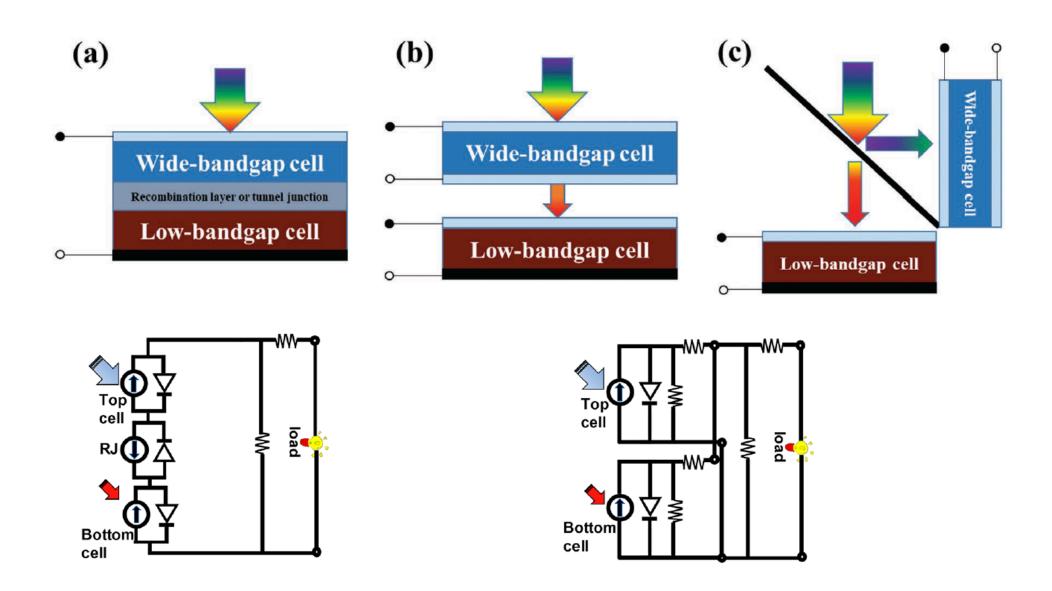


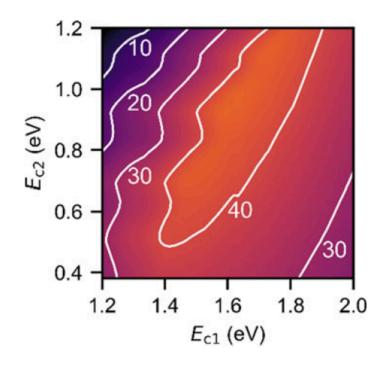
Image taken from https://www.mks.com/n/silicon-epitaxial-thin-films

- Epitaxy is defined as the "regularly oriented growth of one crystalline substance on another".
- Lattice mismatch, ε < 9%, is necessary for obtaining epitaxy.

$$\varepsilon = \frac{a_f - a_s}{a_f}$$

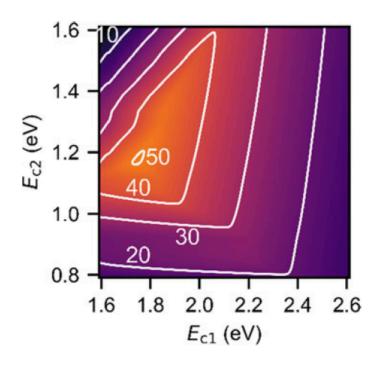
 a_f : lattice constant of the film a_s : lattice constant of the substrate





A dual junction solar cell:

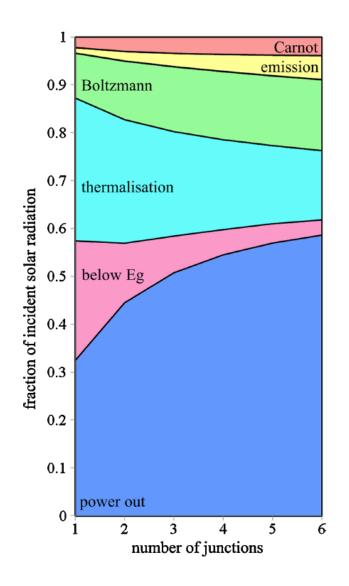
At the point $E_{c1} = 1.58$ eV and $E_{c2} = 0.94$ eV, the conversion efficiency reaches its maximum of **45.4%**.

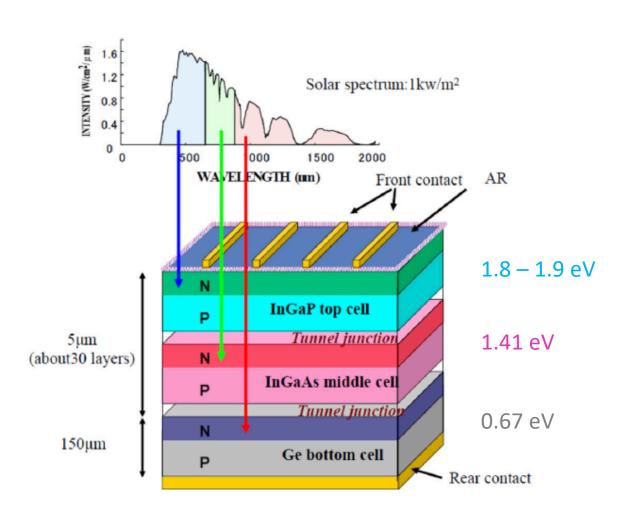


A triple junction solar cell:

With Ge (E_{c3} = 0.66 eV), at the point E_{c1} = 1.76 eV and E_{c2} = 1.18 eV, the conversion efficiency reaches its maximum of **50.3%**.

EPFL III-V Semiconductors: Multijunction Solar Cells



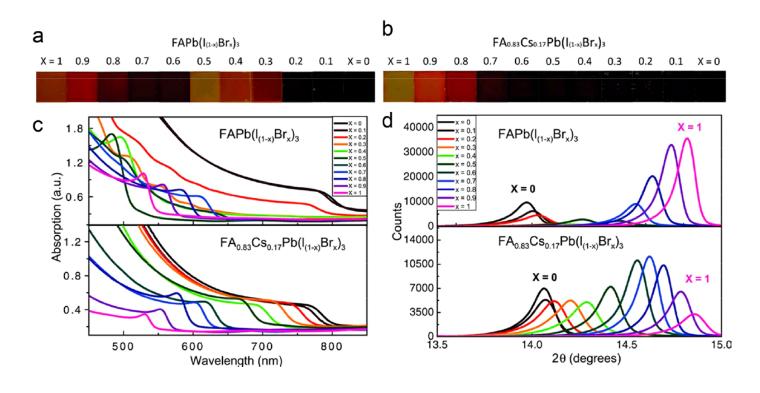


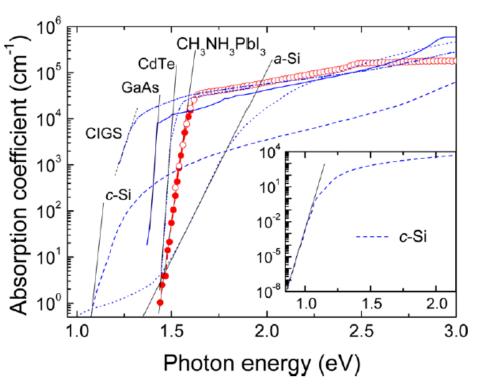
Hirst et al., *Prog. Photovolt: Res. Appl.*, **19**, 286–293 (2011)

Yamaguchi et al., J. Appl. Phys., 129, 240901 (2021)

EPFL Halide Perovskite is Ideal for Tandem Solar Cells?

- Optical bandgap: 1.57 eV
- Band gap Tuning
- No optically detectable deep states.
- Highest reported V_{oc} values: c-Si = 0.75 V, GaAs = 1.12 V, $CH_3NH_3PbI_3 = 1.05 V$.





D. P. McMeekin, *Science*, **351**, 151–155 (2016).

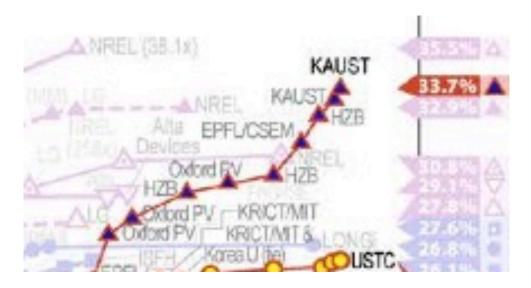
S. De Wolf et al., J. Phys. Chem. Lett., 5, 1035-1039 (2014).

EPFL Perovskite/Si Tandem Solar Cell

Tandem cells at 33.7%

KAUST have set a new world efficiency record for its perovskite/silicon tandem solar cells.

https://www.pv-magazine.com/2023/05/30/kaust-claims-33-7-efficiency-for-perovskite-silicon-tandem-solar-cell/

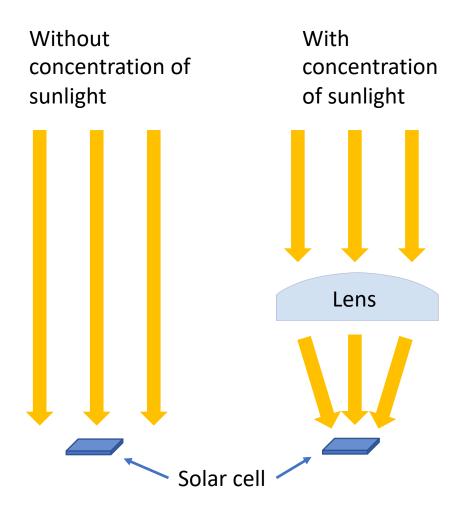


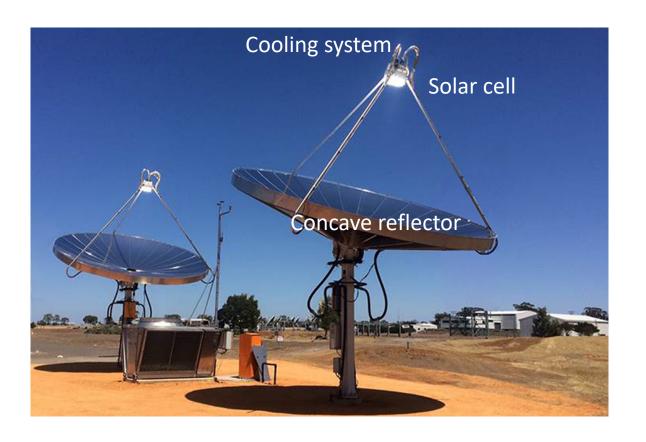




A PCE of 35% is anticipated by increasing the band gap of PSC to 1.7 eV.

EPFL Concentrated Solar Cells





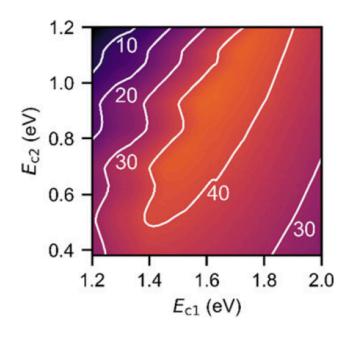
EPFL Concentrated Solar Cells

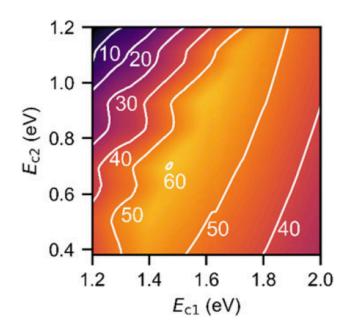
 J_{SC} is proportional to incident optical power density

 V_{OC} increases logarithmically with J_{SC} .

$$V_{OC}(C \times J_{SC}) = \frac{k_B T}{q} \times \ln\left(C \times \frac{J_{SC}}{J_0}\right) = V_{OC}(J_{SC}) + 0.26 \times \ln(C)$$

C = concentration factor

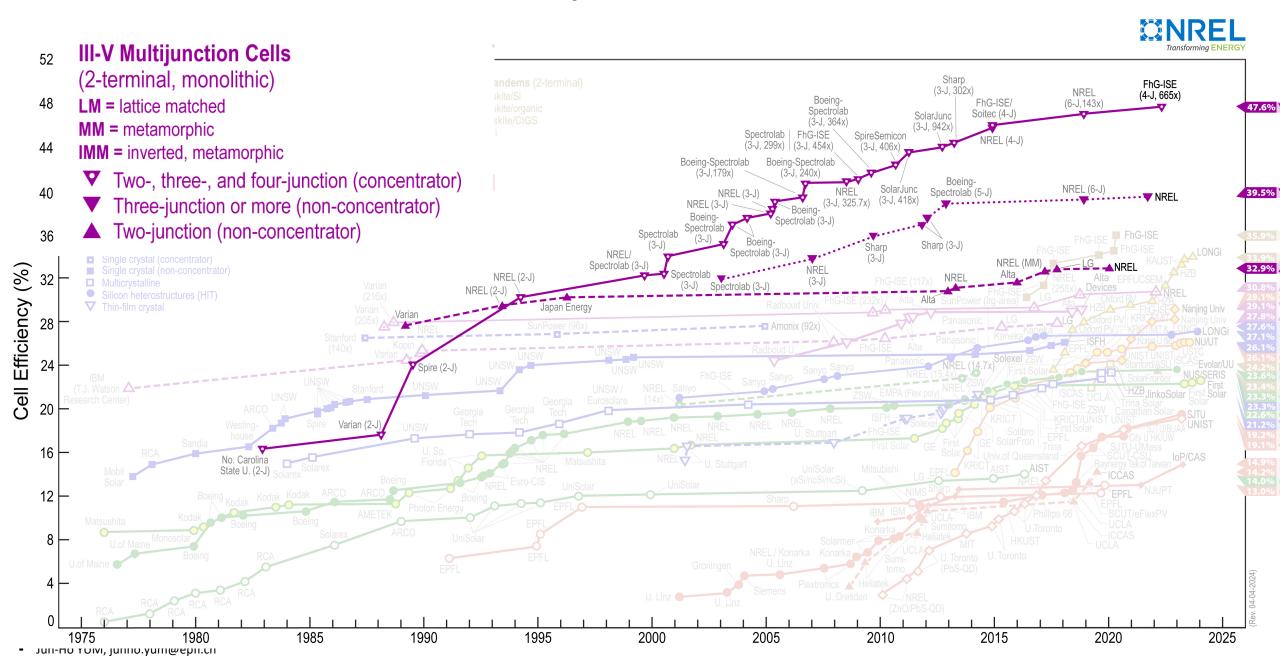




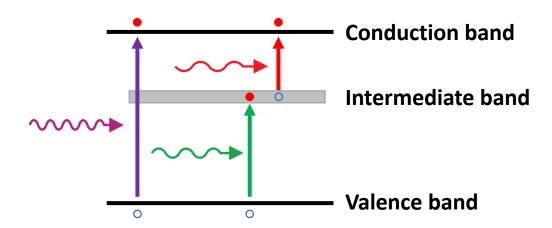
The conversion efficiency of the dual-junction solar cell under **unconcentrated light (45.4%)**.

The conversion efficiency of the dual-junction solar cell under **concentrated light (C = 1000)** and it reaches the maximum of **60%** at $E_{c1} = 1.44$ eV and $E_{c2} = 0.70$ eV.

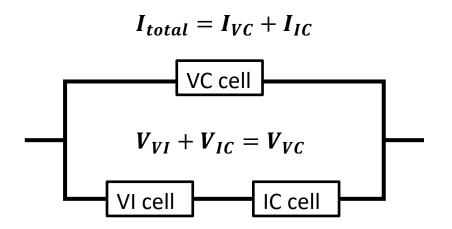
EPFL III-V Semiconductors: Multijunction Solar Cells

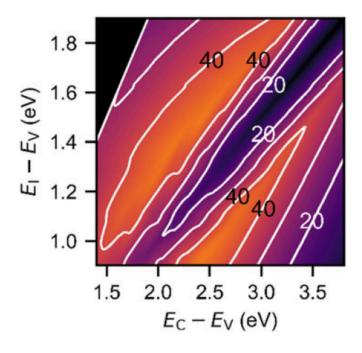


EPFL Intermediate-band Solar Cells



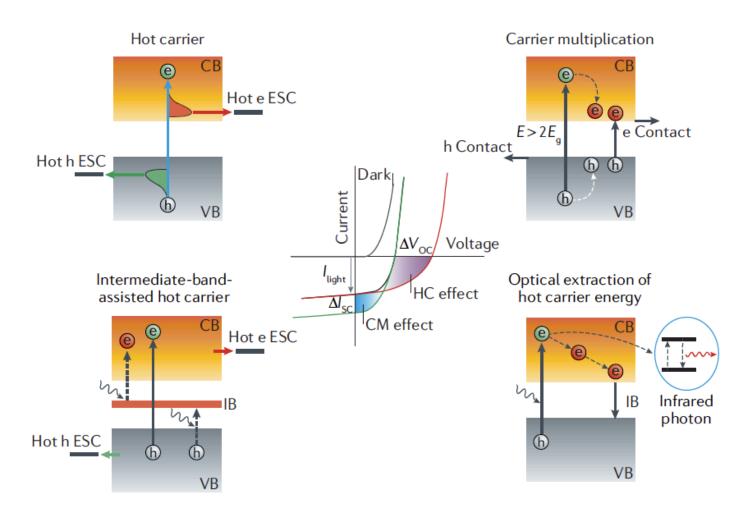
Less sensitive to illumination condition due to the direct absorption via inter-band transition and a stepwise absorption via the intermediate band.

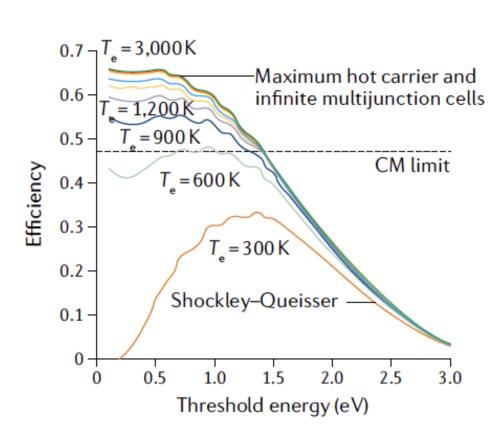




A maximum conversion efficiency of **49.4%** is reached for a band-gap energy of 2.43 eV between the CB and the VB, and an energy gap of 1.49 eV between the valence band maximum (VBM) and the intermediate-band quasi-Fermi level.

EPFL Hot Carrier Generation and Carrier Multiplication





ESC: energy- selective contacts